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# Interfacial interactions of doped-Ti<sub>3</sub>C<sub>2</sub> MXene/MAPbl<sub>3</sub> heterostructures: surfaces and the theoretical approach?

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The work function (WF) of perovskite materials is essential for developing optoelectronic devices enabling efficient charge transfer at their interfaces. Perovskite's WF can be tuned by MXenes, a new class of two-dimensional (2D) early transition metal carbides, nitrides, and carbonitrides. Their variable surface terminations or the possibility of introducing elemental dopants could advance perovskites. However, the influence of doped-MXenes on perovskite materials is still not fully understood and elaborated. This study provides mechanistic insight into verifying the tunability of MAPbl<sub>3</sub> WF by hybridizing with fluorine-terminated Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> (F-MXene) and nitrogen-doped Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> (N-MXene). We first reveal the interfacial interaction between MAPbl<sub>3</sub> and MXenes via X-ray photoelectron spectroscopy (XPS), ultraviolet photoelectron spectroscopy (UPS), and photoluminescence spectroscopy (PL). UPS supported by density functional theory (DFT) calculations allowed the description of the influence of F and N on MXene's WF. Furthermore, we developed MAPbl<sub>3</sub>/MXene heterostructures using F- and N-MXenes. The F-MXenes extended the most WF of MAPbl<sub>3</sub> from 4.50 eV up to 3.00 eV, compared to only a small shift for N-MXene. The underlying mechanism was charge transfer from low WF F-MXene to MAPbl<sub>3</sub>, as demonstrated by PL quenching in MAPbl<sub>3</sub>/F-MXene heterostructures. Altogether, this work showcases the potential of fluorine-doped MXenes over nitrogen-doped MXenes in advancing perovskite heterostructures, thus opening a door for efficient optoelectronic devices.

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## 1. Introduction

Hybrid organic-inorganic perovskites are promising materials for applications in photovoltaic devices due to their high efficiency, low fabrication cost, bandgap tunability, and excellent optical absorption. One of their critical parameters is the work function (WF). Perovskite's WF is an essential parameter for tuning band alignment and charge transfer at materials interfaces, realizing a high photovoltaic device performance.<sup>2</sup> Notably, WF can be tuned by two-dimensional (2D) materials such as MXenes.

MXenes are a novel family of 2D materials called early transition metal carbides, nitrides, and carbonitrides. They are represented by the  $M_{n+1}X_nT_x$  (n = 1-4) chemical formula,

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<sup>†</sup> Electronic supplementary information (ESI) available: Figures: SEM images of F-MXene and N-MXene; EDS of F-MXene; XPS survey spectra of N-MXene and F-MXene; XPS spectra of F-MXene, N-MXene, and the MAPbI<sub>3</sub>/MXene heterostructure; EDS mapping of the F-MXene/MAPbI<sub>3</sub> heterostructure; plane averaged electrostatic potential vs. z for F-MXene, N-MXene, and -OH terminated MXene; PDOS and DOS of -OH terminated MXene, F-terminated MXene, and N-doped MXene; ELF of F-MXene FCC and N-MXene HCP; SECO signals of MAPbI<sub>3</sub>. Tables: chemical composition of as-synthesized MXene obtained from EDS; relative formation energy for every adsorption site of F- and N-MXene; summary of MXene WF obtained from experiment and DFT prediction; and summary of WF and VB changes in MXene/ MAPbI<sub>3</sub> heterostructures. See DOI: https://doi.org/10.1039/d3cp04018f

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in which M is a transition metal, and X denotes carbon or nitrogen. Tx refers to functional groups present on MXene surfaces, such as O, OH, and F,3 making MXenes highly dispersible in water and suitable for solution processing methods. 4 MXenes exhibit remarkable physical properties, such as outstanding electrical conductivity (>  $2.0 \times 10^4 \, \mathrm{S \, cm^{-1}}$ ), high carrier density  $(3.8 \times 10^{22} \text{ cm}^{-3})$ , and exceptional carrier mobility (1 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup>). MXene's optoelectronic properties become even more attractive due to their tunability. For instance, MXene's band structure can be altered by changing the transition metal's chemical structure or modifying the surface via functionalization.7

Introducing different surface terminations can control the WF of Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> MXene.<sup>8,9</sup> These experimental findings were confirmed through density functional theory (DFT) calculations, which predicted that the WF of Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> MXene spans a broad energy range from 1.6 eV (-OH termination) to 6.25 eV (-O termination). 10,11 Agresti et al. demonstrated the tunability of perovskite's WF by introducing MXene surface-terminated with -F, -OH, and -O functional groups. 12 Incorporating the Ti<sub>3</sub>C<sub>2</sub>(OH)<sub>2</sub> MXene reduced WF of MAPbI<sub>3</sub> from 4.72 eV to 4.37 eV. The decrease of WF was induced by the dipole interaction and band alignment at the vicinity of the MAPbI<sub>3</sub>/ Ti<sub>3</sub>C<sub>2</sub>(OH)<sub>2</sub> interface, while the power conversion efficiency of MXene-modified perovskite reached 26%. 12 Given the importance of tuneable WF in device fabrication, this behaviour is particularly promising when combined in a heterostructure assembly. WF tuning plays an essential role in the development of optoelectronic devices. The palette of approaches includes improving the charge transfer capability, constructing Schottky barriers, and determining the catalytic surface activity. 13,14

MXenes have also been utilised as functional building blocks for optically active heterostructures. 15-18 MXene-based heterostructures were developed for various applications, including photocatalysts, 15 photodetectors, 16 and photovoltaics. 19 For instance, adding Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> to MAPbI<sub>3</sub> facilitates more efficient electron transfer through the grain boundary.20 Furthermore, several researchers demonstrated other advantages of coupling Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> MXene with perovskites, such as robust optical absorption, 21 WF alignment, 12 controlled nucleation and crystallization of perovskites, 19 and their efficient charge carrier transportation. 22

Elemental doping of MXenes with non-metallic elements could enhance electrical conductivity, providing excellent WF tunability. 23,24 However, an interplay between doped-MXene and perovskite in terms of the electronic structure and WF tuning is still not fully understood, although non-metallic doped MXenes already showed promising results in various opto- and electrochemical properties. For instance, by introducing nitrogen doping into Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> MXene lattices, the electrical conductivity and electron concentration of Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> can be increased compared with pristine Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub>. Furthermore, nitrogen-doped Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> displayed a remarkable performance as an electrode for supercapacitor applications. An improvement of specific capacitance of 460% compared to the pristine led to excellent cyclic stability after 10 000 charge and discharge cycles. 25,26 In microwave absorbing applications, nitrogen

doping can be a suitable alternative for magnetic nanoparticle fillers in Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub>, which are susceptible to oxidation even at room temperature (RT).27

However, mechanisms responsible for the interaction between surface-terminated or doped MXenes and perovskites are still not fully understood, especially in their influence on perovskite's electronic structure and WF. Hence, in this study, we aim to investigate the effect of fluorine termination and nitrogen doping of Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> on interfacial interactions with MAPbI<sub>3</sub> perovskite. We have synthesized F-terminated  $Ti_3C_2T_x$ via conventional HF etching while N-doped Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> through thermal annealing. We further deposited MAPbI<sub>3</sub> on MXene surfaces via a spin-coating technique and verified their optoelectronic properties and WF for F-MXene/MAPbI3 and N-MXene/MAPbI<sub>3</sub> heterostructures.

Results from ultraviolet photoelectron spectroscopy (UPS), X-ray photoelectron spectroscopy (XPS), and photoluminescence spectroscopy (PL) showed that F-termination and N-doping significantly alter the WF of MAPbI<sub>3</sub>. MXenes effectively tuned the band alignment and interfacial charge transfer in MXene/ perovskite heterostructures, which could enhance the optoelectronic device performance. Additionally, performed DFT calculations further supported our experimental findings.

This work demonstrates the potential of non-metal element additives to MXenes as a promising approach for developing high-performance MXene/perovskite heterostructures. Our study provides new insight into the heterostructure design of perovskite-based optoelectronic devices.

## 2. Materials and methods

#### 2.1. Synthesis of $Ti_3C_2T_x$ MXene

Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> MXene was synthesized by selective etching of the Ti<sub>3</sub>AlC<sub>2</sub> MAX phase (Y-carbon Ukraine) with 48 wt% water solution of hydrofluoric acid (Sigma Aldrich, 695068). The 5-day etching process ensured complete etching out of aluminium and allowed high fluorine saturation of the MXene surface. After etching, MXene flakes were washed with distilled water (6000 rpm for 20 min) until the pH reached around 6. Then, MXene was dried overnight in a vacuum oven at 60 °C.

#### 2.2. Synthesis of F-terminated and N-doped MXene

In order to delaminate MXene, previously etched MXene powders with high fluorine saturation (0.3 grams) were sonicated in methanol for 60 min. Next, the delaminated MXene was centrifuged at 3500 rpm for 10 min to separate MXene from methanol. The sediment was further dried to collect MXene powders. As the MXene powders were highly functionalized by fluorine, we called it F-MXene in the entire paper. The dried MXene was then separated into different alumina crucibles for use in a tube furnace. Nitrogen-doped MXene (N-MXene) was acquired via thermal annealing 100 mg of as-etched MXene at 200 °C for 7 hours under a constant flow (10 sccm) of 10% ammonia in argon (10% NH<sub>3</sub>:90% Ar, Air Products). Au on Si and Si/SiO<sub>2</sub> substrates were used to compare the physicochemical properties

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of MXene in different electronic environments. The powders of F-MXene and N-MXene were further dispersed in methanol and drop-casted on 100 nm-thick Au on Si or Si/SiO<sub>2</sub> substrates.

#### 2.3. MAPbI<sub>3</sub> thin film fabrication

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Perovskite thin films were deposited on previously prepared MXene on the top of 100 nm-thick Au on Si or Si/SiO $_2$  substrates. Hereafter, the prepared films were denoted as the MAPbI $_3$ /MXene heterostructure. The perovskite solution was prepared by dissolving MAI and PbI $_2$  with a molar ratio of 1:1 in  $N_sN$ -dimethylformamide (DMF) (0.5 M) and stirred at 100 °C until complete dissolution. The MAPbI $_3$  thin film was prepared by spin-casting a precursor solution on the top of MXene samples at 2000 rpm (acceleration = 500 rpm) for 30 s and blow-drying with  $N_2$  during the last 15 s when the sample was spinning, giving a thickness of  $\sim$  500 nm. The thin film was then placed on the surface of a hot plate and annealed at 100 °C for 15 min. MAPbI $_3$  was relatively stable within humidity and the sample could withstand  $\sim$ 1 week in the open air. However, the measurement was performed using the as-received sample (same day) to avoid damaging the samples.

#### 2.4. Morphology and structural characterization

The as-prepared  $Ti_3C_2T_x$  (F-MXene) powder morphology was characterized using field-emission scanning electron microscopy (FESEM) of Hitachi S5500, Japan. Moreover, the morphology of F-MXene and N-MXene thin films was characterized using FESEM JEOL JSM-7600F, Japan. The micrographs were taken at an accelerating voltage of 6 kV in the secondary electron mode. The crystal structures of the  $Ti_3AlC_2$  MAX phase and  $Ti_3C_2T_x$  were studied using a Bruker D8-Advance X-ray diffractometer (Cu K $\alpha$  -0.154056 nm). The entire experiment was carried out at RT.

#### 2.5. XPS and UPS measurements

XPS experiments were carried out using an X-ray source of Magnesium Kα with a typical excitation energy output of 1254 eV. The XPS spectra were fitted using the Shirley background. UPS measurements were performed using a VG ESCA Lab system, an ultrahigh vacuum (UHV) system with a typical base pressure in the range of  $\sim 10^{-10}$  mbar equipped with a gas discharge lamp in which helium gas was passed into the analysis chamber. The UV source was an unfiltered He Ia (21.2 eV) excitation, and the sample was biased at -5 V to extract the low-energy secondary electron cut-off (SECO). The UV light spot size on the sample is about 1 mm in diameter. All the reported photoemission spectra were calibrated by referencing the Ag 3d<sub>5/2</sub> peak position (centered at 368.10 eV) of silver polycrystalline foil cleaned by standard argon ion sputtering treatment. The errors of all given values of binding energies and SECO positions are estimated to be  $\pm 0.05$  eV.

#### 2.6. Steady state and dynamic PL measurements

We used a standard micro-PL setup at RT using free-space excitation. The samples were excited with a picosecond-pulsed ytterbium fiber laser emitting at 266  $\pm$  2 nm and 532  $\pm$  2 nm wavelength with a repetition rate of 10 MHz. The emission was

observed through a 0.65-numerical-aperture visible-near-infrared microscope objective, by which the beam diameter was estimated to be 1  $\mu m$ . PL spectra were recorded using an AvaSpec-HSC1024x 58TEC-EVO spectrometer. Time-resolved (TR-) PL measurements were carried out using single-photon counting detector modules from Micro Photon Devices connected to the single-photon counting acquisition module (TCC900, Edinburgh Instruments). We filtered the emission with a bandpass filter at 450  $\pm$  25 nm or a long pass filter at 650 nm.

#### 2.7. Computational methods

Theoretical calculations were carried out using the Quantum ESPRESSO (QE) package. <sup>29</sup> We employed an exchange–correlation functional developed by Perdew–Zunger <sup>30</sup> and the scalar-relativistic ultrasoft pseudopotential. The pseudopotential was chosen similar to the previous calculation. <sup>12</sup> We used a Monkhorst–Pack k-point mesh of  $7 \times 7 \times 1$  and a plane wave basis set cutoff of 60 Ry based on our optimization, as shown in Fig. S1 (ESI†). About  $\sim 10$  Å vacuum was added within all calculations to the MXene structure to avoid the interaction with its image in the z-direction. The F and N surface terminations were added according to the previous report. <sup>8</sup> The work functions were calculated from the electrostatic potential calculated using the pp.x code in QE. The obtained electrostatic potential was further averaged in the z direction using the average from the x code in QE to obtain the work function.

We further performed N-doped  $\text{Ti}_3\text{C}_2\text{T}_x$  MXene calculation using a 3 × 3 × 1 supercell, where one of the carbon atoms was replaced by a nitrogen atom. The adsorption sites of –F and –OH were chosen to be face-centred cubic (FCC) and hexagonal closed-packed (HCP), respectively, owing to the most energetically favourable configurations.

## 3. Results and discussion

MXene nanoflakes were prepared by etching the parental Ti<sub>3</sub>AlC<sub>2</sub> MAX phase in 48 wt% aqueous HF solution. In this study, the etching process was done for five days to ensure the fluorine species fully terminated MXene. The synthesized F-MXene showed characteristic few-to-multilayered flakes (Fig. 1(a)) with a typical accordion-like open structure (Fig. S2, ESI†).31,32 The X-ray diffraction pattern confirmed the successful preparation of Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> MXene (F-MXene), as evidenced by broader XRD peaks and the absence of the corresponding Ti<sub>3</sub>AlC<sub>2</sub> patterns (Fig. 1(b)).<sup>33</sup> Additionally, no diffraction patterns of TiO2 were observed, implying the high quality of synthesized Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> MXenes. Energy dispersive X-ray spectroscopy (EDS) analysis showed the presence of Ti, C, F, and O elements, with a negligible amount of Al (Fig. S3, ESI†). Interestingly, we obtained a high amount of F elements, suggesting dominant F-termination on the F-MXene surface, as we hypothesized before (Table S1, ESI†). After performing the nitrogen doping process, the surface morphology of MXene remains intact, as shown in Fig. S4 (ESI†).

(a)

(b)

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(c)

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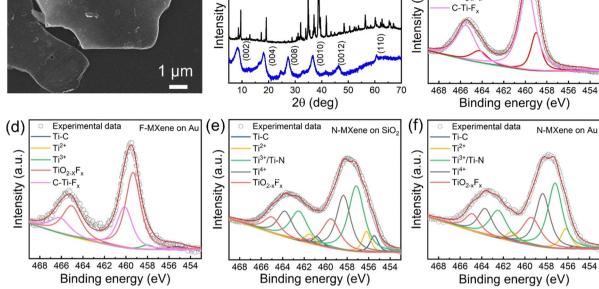


Fig. 1 (a) Scanning electron microscopy (SEM) images of as-synthesized F-MXene. (b) X-ray diffractogram of the Ti<sub>3</sub>AlC<sub>2</sub> MAX phase and as-synthesized F-MXene. Ti 2p fitted X-ray photoelectron spectroscopy (XPS) components of (c) F-MXene on SiO<sub>2</sub>, (d) F-MXene on Au, (e) N-MXene on SiO<sub>2</sub>, and (f) N-MXene on Au.

We further conducted XPS analysis to study the chemical composition of F-MXene and N-MXene drop-casted on SiO2 and Au substrates. XPS survey spectra (Fig. S5, ESI†) revealed the presence of Ti, C, and O in both F-MXene and N-MXene. In addition, F-MXene exhibited a strong fluorine signal, indicating successful fluorine surface termination, which aligns with EDS results. We detected the presence of nitrogen in the XPS survey spectra of N-MXene, indicating the successful introduction of nitrogen doping. In addition, we analysed each of the XPS survey spectra of the samples in a similar route as outlined by Deeva et al.34 The elemental quantification of the F (N) to metal ratio of the respective samples are presented in Fig. S6 (ESI†). By comparing the area of F 1s and Ti 2p peaks, we unravel that the F/Ti ratio yields a high concentration of ca. 1.49 when the as-prepared F-MXenes were introduced onto the Au substrate. Our analysis here is in agreement with the previous report by Halim et al.35 strengthening the fact that F has the dominant fraction of termination groups for Ti-based MXenes. Interestingly, a reasonable concentration (0.42) was achieved when these doped-MXenes were deposited onto SiO<sub>2</sub>. In the case of N-MXene samples, we find a slightly reduced N/Ti ratio (0.17) on SiO2 and (0.18) on Au. Based on this recent investigation, each of the T<sub>x</sub> surface group functionalization in Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> samples shows a contrasting atomic concentration profile of F(or N) species with respect to its metal constituent (Ti). The information regarding the ratio between F (N) and Ti could be further utilised to model MXene terminated locally by F or N. We envision that this will give a more precise local dipole distribution and detailed analysis of

the  $T_x$  species role as demonstrated by Schultz *et al.*<sup>8</sup> and Gouveia *et al.*<sup>36</sup>

The fitted Ti 2p XPS peaks of F-MXene deposited on SiO<sub>2</sub> (Fig. 1(c)) and Au (Fig. 1(d)) showed the presence of diverse Ti components, including Ti–C (455.3 eV),  $\text{Ti}^{2+}$  (456.3 eV),  $\text{Ti}^{3+}$  (458 eV),  $\text{TiO}_{2-x}F_x$  (459.35 eV), and C–Ti–F<sub>x</sub> (460.12 eV).  $^{35,37}$  In this regard, the fluorine-related species, *i.e.*,  $\text{TiO}_{2-x}F_x$  and C–Ti–F<sub>x</sub>, are observed to be present in substantial amounts. It is important to note that the value of the oxide component in F-MXene is located at a higher binding energy than pure TiO<sub>2</sub> oxides ( $\sim$  458.6 eV), indicating that the formed TiO<sub>2</sub> is majorly doped/terminated with F atoms.  $^{37}$  This finding is reasonable as the HF etching process was performed for 5 days, resulting in high –F coverage on the surface of Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub>.

In the case of N-MXene, nitrogen doping causes a redshift of the Ti 2p spectra. The redshifting suggests that the chemical environment of N-MXene differs from that of F-MXene. The fitted Ti 2p XPS spectra of N-MXene on SiO<sub>2</sub> and Au are presented in Fig. 1(e) and (f), respectively. Ti 2p XPS spectra of N-MXene can be fitted into five different components, consisting of Ti–C (455.48 eV), Ti<sup>2+</sup> (456.2 eV), Ti<sup>3+</sup>/Ti–N (457.15 eV), TiO<sub>2</sub> (458.34 eV), and TiO<sub>2-x</sub>F<sub>x</sub> (459.49 eV). In contrast to F-MXene, N-MXene showed a significant contribution of Ti<sup>3+</sup>/Ti–N, implying that nitrogen atoms substitute titanium atoms in the MXene crystal lattice.<sup>23</sup> These findings suggest that the chemical composition and oxidation states of MXene can be effectively tuned through doping, which can significantly impact various applications, including optoelectronic devices.

Fig. S7 (ESI†) presents the O 1s XPS spectra of F-MXene and N-MXene, providing insight into the functional groups on the respective surfaces. For F-MXene, the spectra show the contribution from TiO<sub>2</sub> (529.8 eV), C-Ti-O<sub>r</sub> (531.7 eV), and C-Ti-(OH)<sub>r</sub> (532.7 eV). Therefore, the XPS core levels of O 1s and Ti 2p confirm that F-MXene is successfully functionalized with the mix of -F, -OH, and -O functional groups. On the other hand, O 1s XPS spectra of N-MXene are fitted by TiO<sub>2</sub> (529.8 eV), C-Ti-(OH)<sub>r</sub> (532.3 eV), and N-O (534.5 eV). In contrast to F-MXene, N-MXene is majorly terminated by the -OH functional group. Additionally, N-O suggests partial nitrogen incorporation within the surface functional groups.<sup>38</sup> Nonetheless, we also observe a minor contribution of the -F functional group on N-MXene, which we will discuss further through XPS F 1s analysis.

Fig. S8 (ESI†) shows the F 1s XPS spectra of F-MXene and N-MXene. Here, F-MXene spectra can be fitted into three components, including C-Ti- $F_x$  (684.6 eV), TiO<sub>2-x</sub> $F_x$  (685.2 eV), and  $AlF_x$  (686.2 eV). The presence of the  $AlF_x$  component is attributed to the by-product generated during the etching process.35 On the other hand, N-MXene spectra show two components, namely C-Ti-F<sub>r</sub> (684.1 eV) and Al(OF)<sub>r</sub> (688.3 eV), with the latter originating from the synthesised by-product. Moreover, we emphasize that the -F terminated related species account for only a small fraction of N-MXene. In contrast, F-MXene exhibits a high amount of -F terminated Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub>, indicating the rich surface fluorine (-F) termination on the MXene surface.

To further explore the nature of nitrogen doping in N-MXene, we move to the N 1s core level of XPS spectra. The fitted N 1s XPS spectra of N-MXene (Fig. S9, ESI†) exhibit a significant contribution from Ti-N (396.5 eV),<sup>39</sup> with a minor contribution from O-Ti-N (397.3 eV)<sup>40</sup> components. The presence of Ti-N in both Ti 2p and N 1s XPS spectra confirms the successful lattice substitution of C atoms with N atoms in the Ti<sub>3</sub>C<sub>2</sub>T<sub>r</sub> structure.25,38 Furthermore, O-Ti-N can be connected to the decoration of nitrogen on the surface functional groups. Therefore, in our study, in addition to nitrogen substituting carbon atoms, as indicated by the Ti-N component, nitrogen also decorated the MXene surface, as demonstrated by the O-Ti-N XPS component.

Following the successful synthesis of F-MXene and N-MXene, we fabricated the MAPbI<sub>3</sub>/MXene heterostructure. To achieve this, thin film layers of MXene and MAPbI<sub>3</sub> were prepared on SiO2 and the Au substrate using the spin-coating technique. Fig. 2(a) provides a schematic illustration of the fabrication process of the MAPBI<sub>3</sub>/MXene heterostructure. In particular, MAPbI<sub>3</sub> layers were spin-coated on as-fabricated MXene layers. The heterostructured films show similar thicknesses (around 2 µm) as measured in MXene and MAPbI<sub>3</sub> alone. This observation could be attributed to the consistency of the films obtained from the MXene drop-casting process and the deposited films' relatively thick nature. Tilted SEM images of F-MXene, MAPbI<sub>3</sub>, and MAPbI<sub>3</sub>/MXene thin films deposited on the SiO<sub>2</sub> substrate are displayed in Fig. 2(b)-(e). The SEM images confirm that the perovskite film well penetrated into MXene layers. Interestingly, upon MAPbI3 deposition on the MXene surface, the morphology of the thin film shows a smooth layer. This is attributed to the role of functional groups on the MXene surface in ensuring uniform blending between MXene and perovskite without introducing any aggregation. Furthermore, the EDS mapping of the heterostructured film (Fig. S10, ESI†) confirmed the presence of both  $Ti_3C_2T_x$  and MAPbI<sub>3</sub>.

We further performed XPS measurements to probe the chemical composition of the MAPbI<sub>3</sub>/MXene heterostructured thin film. XPS spectra of MAPbI<sub>3</sub>/N-MXene and MAPbI<sub>3</sub>/F-MXene

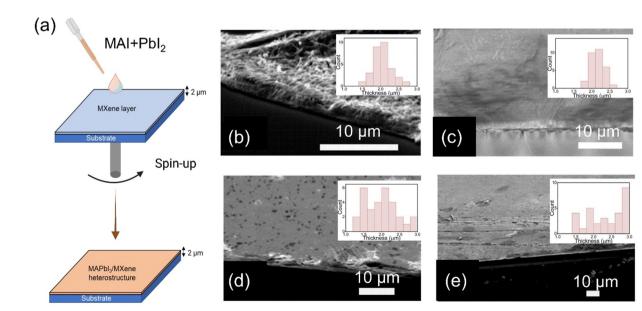


Fig. 2 (a) Schematic diagram of the MAPbl<sub>x</sub>/MXene heterostructure fabrication procedure. Tilted cross-sectional SEM images of (b) F-MXene, (c) MAPbl<sub>3</sub>, (d) N-MXene/MAPbl<sub>3</sub>, and (e) F-MXene/MAPbl<sub>3</sub> thin films deposited on the SiO<sub>2</sub>/Si substrate. The inset shows the thickness distribution of the films. All thicknesses are about 2 µm, indicating perovskite layers were well penetrated to the MXene structure.

grown on SiO<sub>2</sub> and Au substrates are presented in Fig. S11-S14 (ESI†). All the samples show C 1s, N 1s, O 1s, Ti 2p, Pb 4f, and I 3d XPS signals. Pb 4f shows symmetrical doublet peaks corresponding to the spin-orbit splitting of Pb  $4f_{7/2}$  and  $4f_{5/2}$  components from the Pb<sup>2+</sup> cation in the MAPbI<sub>3</sub> crystal structure.<sup>41</sup> We do not observe any Pb 4f components located at a lower binding energy, indicating that no metallic Pb is formed during the perovskite preparation.<sup>42</sup> Furthermore, the I 3d core level shows a single doublet peak, originating from  $3d_{5/2}$  and  $3d_{3/2}$ , showing that only a single I component was observed in the film. Besides the contribution of I 3d and Pb 4f signals, we also observe the N 1s core level, which is related to the MA<sup>+</sup> of the MAPbI<sub>3</sub> structure. 43 As MAPbI<sub>3</sub> is deposited on the surface of MXene, the absence of the Ti 2p signal suggests that MAPbI3 effectively covers the MXene surface. Thus, our XPS analysis confirms the successful fabrication of an MAPbI<sub>3</sub>/MXene heterostructured thin film.

Using the UPS technique, we investigate the electronic structure of the MAPbI<sub>3</sub>/MXene heterostructure. First, we analysed the SECO region of F-MXene and N-MXene without perovskite addition, as presented in Fig. 3(a). We found that the extracted WF of F-MXene deposited on SiO2 and Au are 3.62 and 3.68 eV, respectively. The WF of both samples only shows slight shifting between each other, which is still in the

experimental error range of the measurement. Furthermore, WFs of N-MXene on SiO2 and Au are estimated to be 4.22 and 4.30 eV. Here, we notice a slight shift (0.08 eV) in the WF of N-MXene when different substrates were used. Based on the previous studies, the variation of the WF value can be attributed to the interface dipole and band bending effect at the film/ substrate interface, 44,45 and functional groups present on the MXene surface.8 However, in our case, the former can be neglected, considering the probing depth of UPS is about 2-3 nm<sup>46</sup> and our films have a thickness of 2 μm. Based on the study by Tamulewicz et al. the substrate effects on WF become important when we go down to the single or few-layer scale.<sup>47</sup> Thus, we can conclude that there is a variation in surface functional groups present in N-MXene grown on Au and SiO2 substrates, leading to a slight difference in WF.

It is important to note that the WF of  $Ti_3C_2T_x$  MXene strongly depends on the surface functional groups determined by the synthesis procedure.<sup>8,12</sup> Based on the DFT result, the calculated WF of bare Ti<sub>3</sub>C<sub>2</sub> is 5.05 eV.<sup>48</sup> Moreover, the UPS determined WF of Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> obtained by HF etching, as reported in different works is 4.42 eV<sup>49</sup> and 4.90 eV.<sup>50</sup> Thus, the WF of our N-MXene and F-MXene thin films are relatively low compared to the previously calculated WF of Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub>, implying that

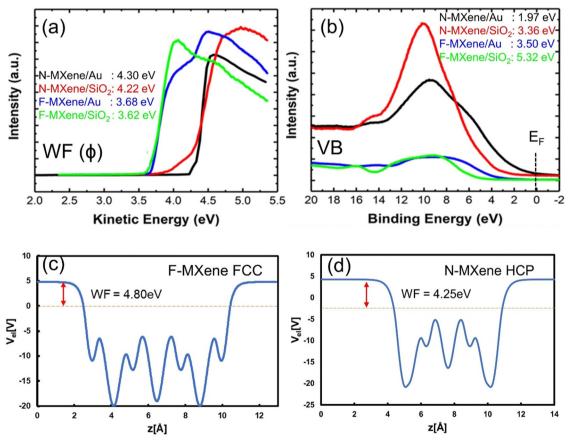


Fig. 3 (a) Secondary electron cut-off (SECO) signals of N-MXenes on Au (black) and SiO<sub>2</sub> (red), F-MXenes on Au (blue), and SiO<sub>2</sub> (green). The extracted work functions (WFs) are presented in the inset. (b) The valence band spectra of MXenes were recorded in various substrates and their corresponding extracted valence band maxima are shown in the inset. (c) Plane averaged electrostatic potential of F-MXene face-centred cubic (FCC) and (d) N-MXene hexagonal closed-packed (HCP) (zero referenced as the Fermi energy)

F and N atoms may act as n-dopants in the Ti<sub>3</sub>C<sub>2</sub>T<sub>r</sub> structure. Next, we analyse the valence band region of F-MXene and N-MXene, as depicted in Fig. 3(b). The spectra show the intensity starting from the Fermi energy and peaking at a binding energy value of around 10 eV. It is worth noting that in the case of F-MXene, the intensity is relaxed compared to N-MXene.

To provide a theoretical basis for our experimental findings, we performed density functional theory (DFT) calculations to investigate the electronic structure of F-MXene and N-MXene. The average electrostatic potential was calculated to determine the WF of MXene, with fluorine and nitrogen atoms positioned in different adsorption sites, i.e., bridge, FCC, HCP, and top sites.8 From our UPS results, the WF of F-MXene is between 3.62 and 3.68 eV. The WF is smaller compared to the result obtained from DFT with the most stable configuration being fluorine atoms adsorbed on the FCC site with a value of 4.80 eV (Fig. 3(c) and Table S2, ESI†). Surprisingly, other adsorption sites give higher WFs of 4.80, 4.04, and 8.34 eV for bridge, HCP, and top sites, respectively (Fig. S15, ESI†). It is important to note that based on our XPS results, F-MXene is also terminated by a minor contribution from -OH groups. Therefore, such a low WF of F-MXene, as determined by UPS can be attributed to the co-existence of -OH groups on the MXene surface. To prove this hypothesis, we calculate the WF of -OH terminated Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> MXene at different adsorption sites (Fig. S16, ESI†). Here, all of the -OH terminated MXene exhibit a low WF ranging from 1.87 to 2.55 eV, implying the contribution of -OH termination in lowering the WF of F-MXene.

For N-MXene, the theoretical WF obtained for the HCP site is 4.25 eV (Fig. 3(d)), which is consistent with the experimental value obtained by UPS analysis i.e., 4.22 eV (N-MXene on SiO<sub>2</sub>) and 4.30 (N-MXene on Au). The HCP adsorption site is the most energetically favourable site for N adsorption (Table S3, ESI†). The previous result shows that MXene contains up to  $\sim 30$  at% of oxygen in the carbon layers, which is inherited from the MAX phase due to its decomposition/selective oxidation.<sup>51–53</sup> Thus, the good agreement between our DFT and experimental results indicates the high quality of synthesized F-MXene and N-MXene, without major contribution from oxygen incorporation in the MXene crystal structure (oxycarbides) and its oxidized species counterpart. Interestingly, we observe a considerable WF-increasing trend for other nitrogen adsorption sites, reaching 7.73, 7.66, and 9.02 eV, for bridge, FCC, and top sites, respectively (Fig. S17, ESI†). This variation can be explained by the difference in the density of electronic states available at the Fermi level, as we will explain later. The details of WF evolution in F-MXene and N-MXene are summarised in Table S4 (ESI†). Based on experimental and simulation results, introducing fluorine on the MXene surface yields a relatively low MXene WF, while nitrogen termination has the opposite role in obtaining a high WF. These findings demonstrate the potential for tuning the WF of MXene through the doping process, which is important for optoelectronic applications.

In addition to WF calculation, we also performed a theoretical investigation on the density of states (DOS) and partial

density of states (PDOS) of F-MXene and N-MXene. Specifically, we calculated the DOS and PDOS for different adsorption sites of fluorine and nitrogen atoms on MXenes. Fig. S16a (ESI†) shows the DOS and PDOS of F-MXene with varying fluorine atom adsorption sites, i.e., bridge, FCC, HCP, and top sites. We found that all the adsorption configurations exhibited metallic behaviour, with the Fermi energy being filled with Ti 3d states. The valence band of the bridge, FCC, and HCP F-MXene arose from hybridization between F 2p and Ti 3d states. While in the top F-MXene site, we observed a different band structure characteristic with the valence band around -4 eV originating from F 2p states.

Next, we calculated the DOS and PDOS of N-MXene with different adsorption sites, as presented in Fig. S16b (ESI†). Here, we can see that incorporating nitrogen atoms on the MXene surface makes the electronic states at the Fermi energy much higher than F-MXene. However, in the case of N-MXene with the HCP site, the total electronic states at the Fermi energy are lower than at other sites. Unlike F-MXene, the Fermi energy of N-MXene resulted from N 2p, C 2p, and Ti 3d hybridization, suggesting the orbital hybridization between nitrogen, carbon, and titanium atoms plays a significant role in the electronic structure (Fig. 4(a) and (b)). This is happening due to the presence of a covalent bond between the C atom in Ti<sub>3</sub>C<sub>2</sub> and the adsorbed N on the HCP site (Fig. 4(d)), which is not present in the F-MXene (F adsorbed on FCC site) counterpart (Fig. 4(c)). To further support this argument, we plot the electron localization function (ELF), which can be used to characterize the bonding behaviour<sup>54</sup> of N-MXene shown in Fig. S19 (ESI†). The ELF shows the presence of a C-N covalent bond in N-MXene (HCP).

Besides revealing the influence of nitrogen terminations on the electronic band structure, we also calculated the theoretical WF of Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> MXene when a nitrogen atom replaces a carbon site (Fig. 5). This calculation is essential as Ti 2p and N 1s XPS spectra of N-MXene indicate the formation of a Ti-N bond. In this calculation, we used -OH terminated MXene at HCP sites and -F terminated MXene at FCC sites, as these configurations are the most energetically favourable for nitrogen doping. In addition, -F and -OH termination are the main terminations observed in the N-MXene sample, as revealed by O 1s XPS spectra. Here, -OH terminated MXene shows an ultralow WF of 2.42 eV (Fig. 5(a)). On the other hand, F-terminated MXene exhibits a large WF of 4.80 eV (Fig. 5(b)).

Next, we replaced one of the carbon atoms in the Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> lattice with one nitrogen atom. Notably, by performing nitrogen doping, -OH terminated MXene at HCP sites (Fig. 5(c)) underwent a lowering of WF from 2.42 to 2.09 eV. In the case of -F terminated MXene at FCC sites (Fig. 5(d)), WF lowers from 4.80 to 4.69 eV. Thus, we observed a similar decreasing WF trend for both configurations when introducing a nitrogen atom to the lattice. This finding is quite different when nitrogen atoms terminate the MXene surface, in which WF can reach up to 9 eV. Therefore, we argued that the low WF experimental value of N-MXene (4.30 eV for N-MXene on Au and 4.22 for N-MXene on SiO<sub>2</sub>) could also be caused by nitrogen atom that occupied

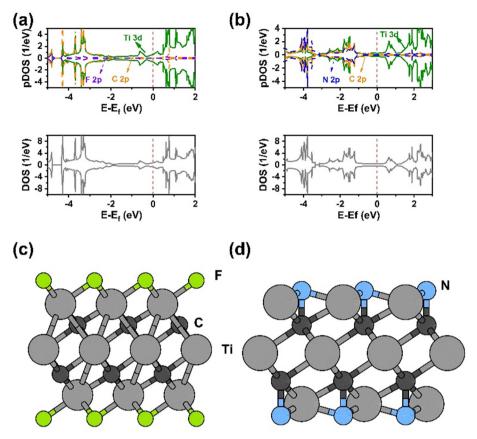


Fig. 4 Partial (PDOS), total density of states (DOS) of (a) F-MXene with the F atom adsorbed in the FCC site and (b) N-MXene with the N atom adsorbed in the HCP site. Optimized structure of (c) F-MXene with the F atom adsorbed in the FCC site and (d) N-MXene with the N atom adsorbed in the HCP site.

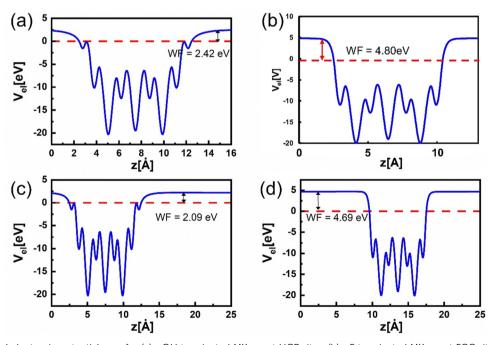


Fig. 5 Plane averaged electronic potential vs. z for (a) -OH terminated MXene at HCP sites. (b) -F terminated MXene at FCC sites. (c) N-doped -OH HCP terminated MXene. (d) N-doped FCC -F terminated MXene. Here, nitrogen doping is performed by replacing one of the carbon atoms in the  $Ti_3C_2T_x$ lattice. -OH HCP and -F FCC termination sites were chosen as these configurations are energetically favourable for performing nitrogen doping.

the carbon lattice of MXene structure partially by forming Ti-N bond as supported by XPS analysis.

Fig. S20a-d (ESI†) displays the PDOS and DOS of N-MXene, where nitrogen replaces one carbon atom. First, by comparing the electronic states between -OH terminated and -F terminated MXene, it becomes clear that -OH termination gives more electronic states at the Fermi level compared to -F terminated MXene. In particular, -OH terminated MXene shows the majority of Ti 3d states at the Fermi level with a weak contribution of C 2p, O 2p, and H 1s hybridizations (Fig. S20a, ESI†). In the case of -F terminated MXene (Fig. S20b, ESI†), we only observe Ti 3d states at the Fermi level.

After we discussed the electronic structures of F-MXene and N-MXene, we moved to the electronic structure of MAPbI<sub>3</sub> grown on Au and SiO2 substrates. The measured SECO region of perovskite samples is presented in Fig. S21 (ESI†). We can see that the secondary electron offset of the spectra gave WF of 4.09 eV and 4.52 eV for MAPbI<sub>3</sub> on Au and SiO<sub>2</sub>, respectively. The differences in these values can be attributed to the different chemical natures of the samples. Previous theoretical studies revealed that the WF of MAPbI3 can be tuned between 4.00 and 4.80 eV for PbI<sub>2</sub> rich and MAI rich, respectively.<sup>55</sup>

Next, we study the MXene WF changes upon the fabrication of MAPbI<sub>3</sub>/MXene heterostructured thin film. The WF estimated by the SECO is presented in Fig. 6(a). By introducing N-MXene into the targeted hybrid perovskite structure, we see that MAPbI3 exhibited a slightly lower WF, i.e., 4.45 eV and 4.35 eV for N-MXene/MAPbI<sub>3</sub> grown on Au and SiO<sub>2</sub>, respectively. Interestingly, a dramatic lowering of WF is observed when MAPbI<sub>3</sub> is combined with F-MXene. MAPbI<sub>3</sub>/F-MXene grown on Au and SiO<sub>2</sub> show WF of 3.00 and 3.45 eV, respectively. Our results suggest that N-MXene and F-MXene act as an n-dopant, which upshifts the Fermi energy of the perovskite towards the vacuum level. In this case, a robust interfacial connection of MXene/ perovskite is established, in which electrons are transferred from low-work function MXene to the perovskite layers and induce the interface dipole.2 A similar mechanism has been experimentally observed in N-doped graphene quantum dot/ MAPbI<sub>3</sub>. <sup>56</sup> To determine the valence band maximum (VBM) of MXene/MAPbI<sub>3</sub> thin film, the UPS valence band region is presented in Fig. 6(b). The VBM of N-MXene/MAPbI<sub>3</sub> thin film deposited on Au and SiO2 are 3.50 and 7.62 eV, respectively. Moreover, in F-MXene/MAPbI<sub>3</sub>, the VBM value is estimated to be 5.12 eV (on Au) and 3.45 eV (on SiO<sub>2</sub>). Table S5 (ESI†) summarised the WF and VBM changes of MAPbI<sub>3</sub>/MXene heterostructure on Au and SiO2 substrates.

We further investigate the optical properties of F-MXene, N-MXene, and MAPbI<sub>3</sub>/MXene heterostructured thin film via PL measurements. Fig. 7(a) reveals that F-MXene and N-MXene exhibit relatively weak PL signals with peaks at 450 and 400 nm, respectively.<sup>57</sup> From our DOS results, F-MXene and N-MXene are good conductors owing to their rich electronic states at the Fermi level. Thus, the weak observed PL signal does not originate from Ti<sub>2</sub>C<sub>2</sub>T<sub>r</sub> flakes. The observed PL emission of the samples corresponds to TiO<sub>2</sub> species on the surface,<sup>57</sup> as we detected TiO2 and TiO2-xFx in both F-MXene and N-MXene in Ti 2p XPS spectra. Furthermore, the slight difference in the PL peak position of N-MXene and F-MXene may be due to different native defects present in the TiO<sub>2</sub> lattice.<sup>57,58</sup>

To further investigate the PL properties of MAPbI<sub>3</sub>/MXene heterostructure in detail, we also examined the PL response of bare MAPbI<sub>3</sub> films. Under 532 nm laser excitation, a strong PL intensity with a broad peak was observed at 766 nm for the corresponding films (Fig. 7(b)), which agrees with the previous reports.<sup>59,60</sup> Moreover, we find that the PL intensity of MAPbI<sub>3</sub> deposition on Au is lower than on SiO2, possibly due to factors such as non-radiative recombination centres, variation in film thickness, and crystal quality.61,62 Upon the formation of MAPbI<sub>3</sub>/MXene heterostructure, the PL is strongly quenched, which might be attributed to the n-doping or charge transfer effect between MXene and perovskite at the interface. 63,64 Additionally, PL quenching is an indicator of excellent interfacial contact in metal/semiconductor heterostructure.65 We measured TR-PL decay curves to further explore the charge carrier dynamics in MXene thin films (Fig. 7(c)). Both N-MXene and F-MXene exhibited a rapid decay, which might be attributed to the charge transfer from light-active TiO<sub>2</sub> to Ti<sub>3</sub>C<sub>2</sub>T<sub>r</sub> through a Schottky interface. TR-PL spectra of MAPbI<sub>3</sub> on SiO<sub>2</sub>

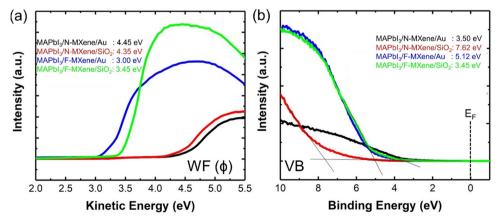


Fig. 6 The spectral evolution of MXenes upon MAPbl<sub>3</sub> doping. (a) The respective values are shown as indicated in the SECO region and (b) the valence band region where the valence band maximum (VBM) is acquired at the interpolation from the spectral edge to the baseline.

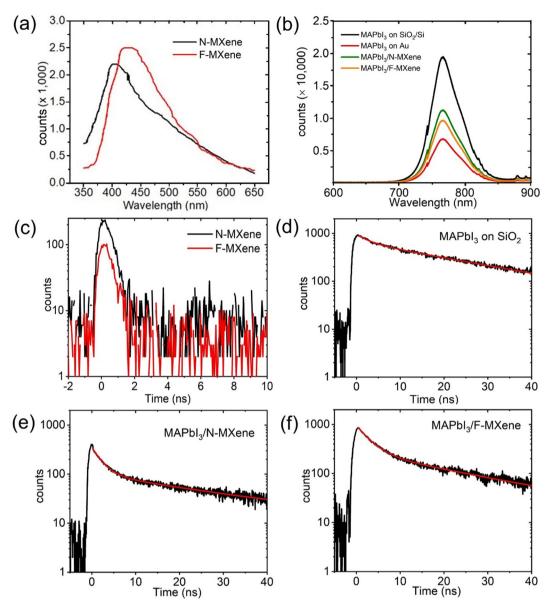


Fig. 7 Optical properties of N-MXenes and F-MXenes and their interactions with MAPbl<sub>3</sub>. (a) Steady-state photoluminescence (PL) spectra of pristine MXenes samples. (b) PL spectra of MAPbl<sub>3</sub>/MXenes heterostructure. Time-resolved PL (TR-PL) decay curve of (c) N- and F-MXenes, (d) MAPbl<sub>3</sub> on SiO<sub>2</sub>, (e) MAPbl<sub>3</sub> on N-MXenes, and (f) MAPbl<sub>3</sub> on F-MXenes. (a) and (c) were obtained with excitation at 266 nm, while (b), (d), (e), and (f) were at 532 nm. Decay curve of (b) for 450 nm emission while those of (d), (e), (f) for emission beyond 650 nm.

thin film are presented in Fig. 7(d). The decay curve is fitted by two components (Table 1). The first decay (2.9 ns) is attributed to the emission from the self-trapped excitons, whereas the second decay (26 ns) is related to the emission from the recombination of free carriers.66 The average decay time of MAPbI<sub>3</sub> on SiO<sub>2</sub> is calculated to be 16.6 ns.

Next, we investigate the decay profile of MAPbI<sub>3</sub>/MXene heterostructure thin films, which has shown promising potential in tuning the performance of perovskite-based optoelectronic devices. As illustrated in Fig. 7(e), TR-PL spectra of MAPbI<sub>3</sub>/N-MXene reveal a decreased average decay time of 14.2 ns, compared to pristine MAPbI<sub>3</sub>, with a decay time of 16.6 ns. Introducing F-MXene in the heterostructure (Fig. 7(f))

Table 1 Extracted parameters from the fitting of TRPL curves

Sample	$\tau_1$ (ns)	$A_1$ (%)	$\tau_2$ (ns)	$A_2$ (%)	$\tau_{\rm avg}  (\rm ns)$
MAPbI <sub>3</sub> on SiO <sub>2</sub>	2.9	5	26.0	95	16.6
MAPbI <sub>3</sub> /N-MXene	2.2	23	26.4	77	14.2
MAPbI <sub>3</sub> /F-MXene	3.0	24	23.8	76	12.5

further decreased the decay time to an average lifetime of 12.5 ns. This faster carrier lifetime in MAPbI<sub>3</sub>/F-MXene, as compared to MAPbI<sub>3</sub>/N-MXene, can be attributed to the more efficient charge transfer pathway provided by F-MXene, resulting in more substantial PL quenching. The different PL quenching is connected to different doped-MXene/perovskite

heterostructure interfacial properties. Previously, Tao et al. demonstrated that the charge transfer ability of Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> can be controlled by introducing different types of surface functional groups. 67 They constructed WS<sub>2</sub>/Ti<sub>3</sub>C<sub>2</sub>T<sub>r</sub> heterostructure and showed that F-MXene has more efficient charge transfer than N-MXene. Thus, our findings demonstrate the potential of F-MXene to tune the electronic structure of perovskite-based optoelectronic devices effectively.

### 4. Conclusion

This study presents a comprehensive interfacial engineering of the optoelectronic properties of Ti<sub>3</sub>C<sub>2</sub>T<sub>r</sub> MXene/MAPbI<sub>3</sub> heterostructures by tuning the WF of MAPbI<sub>3</sub>. We elucidated the chemical states of Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> of respective fluorine termination (F-MXene) and nitrogen doping (N-MXene) by the XPS technique. Fluorine atoms decorated the outermost surface of F-MXene, while nitrogen atoms were partially adsorbed on the N-MXene surface and doped the crystal lattice.

The UPS spectra have shown that the F-termination and N-doping of  $Ti_3C_2T_x$  yield low WFs ranging from 3.34 to 4.30 eV. These experimental results are comparable with DFT results, considering four adsorption sites of the respective atoms (hexagonal closed-packed, face-centred cubic, bridge, and top sites).  $MXene/MAPbI_3$  heterostructures constructed from F-terminated and N-doped MXenes further result in WF tuning of MAPbI<sub>3</sub> within 3.00-4.45 eV. Due to the efficient charge transfer pathway, strong PL quenching and faster average decay time were observed for both heterostructures compared to pristine counterparts.

Altogether, our results show excellent MXene/MAPbI3 heterostructure tunability regarding WF and optical properties by surface termination and non-metal elemental doping. The obtained results formulate an essential step for tailoring the interfacial electronic structure of MXenes toward optoelectronic applications.

## Author contributions

MAKP: investigation, formal analysis, data curation, visualization, and writing - original draft. A: conceptualization, methodology, data curation, resources, supervision, and writing - review & editing. SWK: investigation and validation. FM: investigation and validation. DM: investigation. JM: investigation, formal analysis, visualization, and writing - review & editing. YD: investigation, resources, and writing - review & editing. DK: investigation and writing - review & editing. HL: resources and supervision. MDB: resources, project administration, conceptualization, writing - review & editing, and supervision. AMJ: supervision and writing - review & editing.

## Conflicts of interest

There are no conflicts of interest to declare.

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